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Experimental Demonstration of mid-IR Octave Spanning Supercontinuum Generation in Low Loss Silicon Germanium Waveguide

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Abstract: We report supercontinuum extending from 3 to 6μ m generated in Si0.6Ge0.4/Si waveguide pumping with ~200fs pulses at 4.15 μ m. Experimentally measured low propagation loss (0.4dB/cm in range 3.8-5.0 μ m) and dispersion engineering waveguide allowed us achieving ~5mW useful average power.

OCIS codes: (130.0130) Integrated optics; (190.0190) Nonlinear optics; (320.0320) Ultrafast optics.

The development of broadband light in the mid-infrared (mid-IR – at $3-8\mu$ m) for on-chip sensing of molecules is attracting growing interest. Main atmospheric gases and molecules that are important for our health and security have fundamental absorption lines in the mid-IR. In order to achieve low-cost and large-scale fabrication of compact devices for on-chip sensing, it is of special interest to find efficient group IV based integrated platforms exploiting mature CMOS fabrication processes [1, 2]. A key building block is a stable and broadband light source with adequate output power. Supercontinuum generation sources represent an attractive approach and these have been already demonstrated on a variety of integrated platforms such as silicon-on-insulator, silicon nitride-on-insulator and silicon germanium-on-insulator [3-7]. However, to date this has largely been limited to wavelengths less than ~ 3.5µm mainly due to the absorption in the silica substrate. Subsequently, supercontinuum generation at wavelengths as long as 6µm was reported on silicon-on-sapphire [8], but with a limited average output power due to strong nonlinear loss and absorption beyond 6 µm of the sapphire substrate. Recently, silicon-germanium (SiGe) alloys, have emerged as an attractive alternative platform for mid-IR photonics [9-11], with transparency potentially extending up to 15µm depending on the Ge content [12].



Figure 1 a) Calculated TE mode group velocity dispersion (GVD) blue and effective area mode red, b) Measured propagation loss versus signal wavelength with TE mode profile superimposed to the SEM image of the waveguide

In this work we report octave spanning SCG in the mid-IR from 2.95 to $6.0\mu m$ with a useful average power of ~5mW from a dispersion-engineered low-loss "air clad" Si0.6Ge0.4 waveguide. The waveguide consisted of a 2.7 μm thick Si0.6Ge0.4 ridge 4.25 μm wide on a silicon substrate. Our waveguide was engineered to have single-mode operation in the anomalous dispersion regime across a wide band with low effective area and strong mode confinement (~96% at 4 μm) (figure 1a). As can be seen from the field distribution of the TE mode at 4 μm (inset of figure 1b) this geometry also has the benefit of improving the mode confinement, thereby reducing the contribution from surface roughness to the loss. The measured propagation loss is shown in fig 1b, showing a loss as low as 0.4dB/cm in the broad range from 3.8 to 5 μm . Although being air-clad, these losses are the lowest measured so far in waveguides at mid-infrared wavelengths. Supercontinuum generation was then achieved by pumping the

waveguide with \approx 200fs TE polarized pulses from a mid-infrared MIROPA-fs optical parametric amplifier at a repetition rate of 63MHz. Using a 7cm long waveguide pumped at 4.15µm in the anomalous dispersion regime we obtained the spectra shown in Fig 2a for coupled average pump powers from 0.4mW to 16mW.



Figure 2 a) Output spectra measured at different coupled power, b) Measured output power versus coupled power (black) and normalized nonlinear transmission versus coupled peak intensity (red)

An octave-spanning supercontinuum spectrum with a 3.05µm bandwidth (2.95-6.0µm) at the -30dB level was achieved with 15.8mW coupled average pump power (~35GW/cm² coupled peak intensity). The long wavelength limit was not a result of material absorption but rather was associated with the cut-off of the fundamental mode (around 6.5µm), as induced by the asymmetric waveguide design. Therefore, in principle, this can be extended by using a different geometry. Compared with previous results [9, 10], the lower propagation losses achieved here enabled us to generate supercontinuum at a much reduced pump intensity, thereby limiting the impact of high-order nonlinear absorption (Fig 2b). This translates into an increased supercontinuum average output power of 4-6mW. We also present normalized nonlinear transmission measurements, shown on figure 2b. In contrast to the results reported on silicon waveguides [8, 11], where a strong saturation (~10%) of the transmission occurred at 10GW/cm² coupled peak pump intensity, in our case we observe more than 80% of normalized transmission at this intensity and more than 40% at highest intensity levels. In summary, we report the first supercontinuum generation from a silicon germanium-on-silicon platform in the actual mid-IR wavelength, where most molecules have relevant fingerprints. The generated average mid-IR power exceeds that produced so far by other Si-based platforms. This establishes silicon germanium-on-silicon as a promising platform for integrated nonlinear photonics in mid-IR, with the potential to extend the operating range beyond 8µm.

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